Amendments to the Claims:

This listing of claims replaces all prior versions, and listings, of claims in this application.

Listing of Claims:

- 1-11. (Canceled)
- 12. (Currently Amended) A multi-layered complementary wire structure, comprising: at least one first wire extending in a first direction, the at least one first wire including: a first main line formed in a first conductive layer; and
 - a plurality of first branch lines formed in a second conductive layer spaced from the first conductive layer, each of the first branch lines having a first length and being separated from an adjacent first branch line by a first distance; and

at least one second wire extending in a second direction orthogonal to the first direction, the at least one second wire including:

a second main line formed in the second conductive layer; and

a plurality of second branch lines formed in the first conductive layer, each of the second branch lines having a second length and being separated from an adjacent second branch line by a second distance,

wherein a first ratio of the first length to the first distance and a second ratio of the second length to the second distance are greater than <u>or equal to</u> approximately 2 in order to reduce the resistance of the multi-layered complementary wire structure.

- 13. (Canceled)
- 14. (Canceled)
- 15. (Previously Presented) The multi-layered complementary wire structure according to claim 12, wherein the first ratio of the first length to the first distance ranges between approximately 2 and 9.

- 16. (Previously Presented) The multi-layered complementary wire structure according to claim 12, wherein the second ratio of the second length to the second distance ranges between approximately 2 and 9.
- 17. (Previously Presented) The multi-layered complementary wire structure according to claim 12, further comprising a plurality of contact plugs for connecting the plurality of first branch lines to the first main line.
- 18. (Previously Presented) The multi-layered complementary wire structure according to claim 12, further comprising a plurality of contact plugs for connecting the plurality of second branch lines to the second main line.
- 19. (Currently Amended) A matrix structure of a display, comprising:

a substrate: and

a plurality of transistors arranged in a matrix on the substrate, each of the plurality of transistors is disposed near an intersection of a gate line extending in a first direction and a data line extending in a second direction orthogonal to the first direction and not disposed on the gate line or data line.

wherein the gate line includes:

a first main line formed in a first conductive layer; and

a plurality of first branch lines formed in a second conductive layer spaced from the first conductive layer, each of the first branch lines having a first length and being separated from an adjacent first branch line by a first distance; and the data line includes:

a second main line formed in the second conductive layer; and

a plurality of second branch lines formed in the first conductive layer, each of the second branch lines having a second length and being separated from an adjacent second branch line by a second distance, and

wherein a first ratio of the first length to the first distance and a second ratio of the second length to the second distance are greater than <u>or equal to</u> approximately 2 in order to reduce the resistance of the matrix structure of the display.

- 20. (Canceled)
- 21. (Canceled)
- 22. (Previously Presented) The matrix structure of the display according to claim 19, wherein the first ratio of the first length to the first distance ranges between approximately 2 and 9.
- 23. (Previously Presented) The matrix structure of the display according to claim 19, wherein the second ratio of the second length to the second distance ranges between approximately 2 and 9.
- 24. (Previously Presented) The matrix structure of the display according to claim 19, further comprising a plurality of contact plugs for connecting the plurality of first branch lines to the first main line.
- 25. (Previously Presented) The matrix structure of the display according to claim 19, further comprising a plurality of contact plugs for connecting the plurality of second branch lines to the second main line.
- (Currently Amended) A method for manufacturing a multi-layered complementary wire structure, comprising:

forming a first conductive layer on a substrate;

patterning the first conductive layer to form a plurality of first main lines extending in a first direction and a plurality of second branch lines extending in a second direction orthogonal to the first direction, each of the plurality of second branch lines having a second length and being separated from an adjacent second branch line by a second distance;

forming an insulating layer on the patterned first conductive layer;

patterning the insulating layer to form a plurality of first contact holes exposing portions of each of the plurality of first main lines and a plurality of second contact holes exposing portions of each of the second branch lines; forming a second conductive layer on the insulating layer to fill the first contact holes and the second contact holes: and

patterning the second conductive layer to form a plurality of second main lines extending in the second direction and a plurality of first branch lines extending in the first direction, each of the plurality of first branch lines having a first length and being separated from an adjacent first branch line by a first distance,

wherein a first ratio of the first length to the first distance and a second ratio of the second length to the second distance are greater than <u>or equal to</u> approximately 2 in order to reduce the resistance of the multi-layered complementary wire structure.

27. (Canceled)

28. (Canceled)

- 29. (Previously Presented) The method for manufacturing the multi-layered complementary wire structure according to claim 26, further comprising determining that the first ratio of the first length to the first distance ranges between approximately 2 and 9.
- 30. (Previously Presented) The method for manufacturing the multi-layered complementary wire structure according to claim 26, further comprising determining that the second ratio of the second length to the second distance ranges between approximately 2 and 9.